



## CYCLIC VOLTAMMETRY MEASUREMENT FOR N-TYPE $\text{Cu}_2\text{O}$ THIN FILM USING COPPER ACETATE-BASED SOLUTION

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### ABSTRACT

Cyclic voltammetry (CV) measurement are used to determine the ideal potential range to deposit n-type cuprous oxide by electrodeposition method on fluorine-doped tin oxide (FTO) glass substrate using copper (II) acetate-based solution. Conventional methods of fabrication were time and cost consuming due to no ideal parameter setup. With cyclic voltammetry measurement, redox reaction could not be obtained. Hence, the parameters for fabrication process were optimized. Electrodeposition method was used to deposit the cuprous oxide thin film onto the FTO glass substrate. The selected pH values for this study were pH 5.5 and 6.5 with deposition temperature of 50 and 60 °C. The deposition time was fixed to 60 minutes. N- $\text{Cu}_2\text{O}$  thin films were fabricated and then characterized using Field Emission Scanning Electron Microscopy, X-Ray Diffractometer, Ultraviolet-Visible Spectroscopy and surface profiler. From the results of the analyses, the band gap obtained was 1.8 eV. The structural, morphological and optical properties showed that cuprous oxide with (111) preferred orientation were successfully fabricated.

**Keywords:** cuprous oxide, cyclic voltammetry, electrodeposition, N-type semiconductor.

### INTRODUCTION

Solar cell has emerged as one of the top research for harvesting one of the important sustainable energy sources, solar energy. Harvesting solar energy does not affect the environment as the energy is produced by the sun. Sunlight from the sun can be used directly to generate electricity using photovoltaic technology (Goetzberger, Hebling and Schock, 2003), (Goetzberger, Luther and Willeke, 2002), (Green, 2000). The typical material of a solar cell is silicon. However, the high cost of using the silicon solar cells to capture light energy have forced the development in creating new photovoltaic devices that utilize cheap and non-toxic materials prepared by energy-efficient process (Wohrle and Meissner, 1991).

One of the substituting materials for solar cell application is a metal oxide semiconductors, cuprous oxide ( $\text{Cu}_2\text{O}$ ). The synthesized  $\text{Cu}_2\text{O}$  is typically a p-type semiconductor with a direct band gap of around 2.0 - 2.2 eV which makes it a potential candidate for light energy absorbing layer in solar cell plates. Besides,  $\text{Cu}_2\text{O}$  is attractive due to its high absorption coefficient, comes in abundance, non-toxicity and low cost fabrication (Fernando and Wetthasinghe, 2000) (Han and Tao, 2009) (Musa, Akomolafe and Carter, 1998).

There are many methods have been applied to produce  $\text{Cu}_2\text{O}$  thin film which include sol-gel approach (Akhavan, Tohidi and Moshfegh, 2009), thermal oxidation (Musa, Akomolafe and Carter, 1998), chemical vapour deposition (Jeong and Aydil, 2009), sputtering (Akimoto *et al*, 2006) and electrochemical method (Xue *et al*, 2013), (McShane, 2012). In this study, electrochemical process is chosen because the deposition process is simple,

inexpensive, producing controllable film thickness, producing large scale deposition and can be done at low temperature (Bugarinovic *et al*, 2011), (Katayama *et al*, 2004). Moreover, it has the ability to control the surface morphologies, phase compositions and other elements by adjusting the deposition parameters (Chen, 2013). By using this method, the type of  $\text{Cu}_2\text{O}$  semiconductor can be determined by varying the pH of  $\text{Cu}_2\text{O}$  electrolyte solution. An alkaline condition which is higher than pH 9 will produce a p-type  $\text{Cu}_2\text{O}$  semiconductor while an acidic condition with pH lower than 7.0 will produce an n-type  $\text{Cu}_2\text{O}$  semiconductor (Siripala *et al*, 1996).

Conventional electrodeposition process of thin film is time consuming because the experiment takes longer time to find an ideal potential value for  $\text{Cu}_2\text{O}$  deposition and thus contributed to high cost of process (Shahrestani, 2013), (Wang and Tao, 2007). Thus, an additional process prior to electrodeposition process is suggested which is cyclic voltammetry. Cyclic voltammetry is a simple and direct method for measuring the formal potential of a half reaction when both oxidized and reduced forms are stable during the time required to obtain the voltammograms (current-potential curves) (Evans *et al*, 1983). In this study, cyclic voltammetry was used to plot the ideal region of potential range for n-type  $\text{Cu}_2\text{O}$  thin film deposited at different solution pH and different solution temperature.



## EXPERIMENTAL

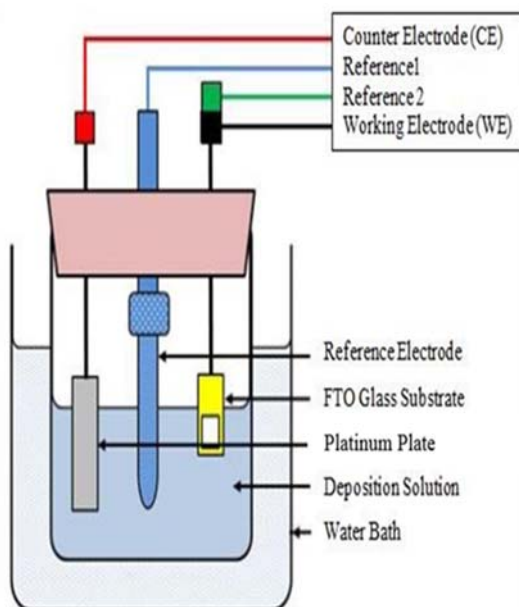
### A. FTO substrate and Cu<sub>2</sub>O solution preparation

Cu<sub>2</sub>O thin films were deposited on FTO substrates via electrodeposition method. Prior to the deposition process, substrates were cut in 2.5 cm x 1.0 cm dimensions, cleaned with acetone in ultrasonicator for 5 min and rinsed with distilled water. An opening area of 1 cm x 1 cm for Cu<sub>2</sub>O deposition was created and the remaining area was covered with kapton tape. The substrates were further cleaned using polarization process with a galvanostat setting of 10 mA/cm<sup>2</sup> for 60 s.

The solution used for n-Cu<sub>2</sub>O deposition on FTO substrate was copper acetate-based solution. 200 mL aqueous solution was made up from mixtures of 0.4 M of copper (II) acetate monohydrate, 3 M of lactic acid and potassium hydroxide (KOH). pH of Cu<sub>2</sub>O solution was fixed to pH 5.5 and 6.5 by adding KOH.

### B. Cyclic voltammogram (CV) measurement and analysis

For this section, the experimental setup was set as in Figure-1. Before executing CV, the setup was tested using open circuit test for rest potential determination as the values are different according to solution pH and temperature. Then, the rest potential was used as the starting and end potential for the CV process. Generally, the potential range applied for this process was between -1.5 V to +1.0 V vs reference electrode (Ag/AgCl). The parameters values were set to 50 and 60 °C for solution temperature and pH 5.5 and 6.5 for solution pH.



**Figure-1.** Experimental setup for cyclic voltammetry and electrodeposition process of Cu<sub>2</sub>O solution.

### C. Cu<sub>2</sub>O electrodeposition process

In order to fabricate Cu<sub>2</sub>O thin film layer, electrodeposition method (Solartron Analytical, 1280C Electrochemical Test System) was used. The experimental setup for this process was the same as in Section B. However, only one potential value was used for deposition which was determined from CV process. The varied parameters remained the same which were the solution pH and temperature.

### D. Characterization and analysis

Several characterization tests were done on the electrodeposited Cu<sub>2</sub>O thin film. The structural characterization was done using X-Ray Diffractometer (XRD) (Bruker, Model D8 Advance), Field Emission Scanning Electron Microscopy (FESEM) (JEOL, Model JSM-7600F) for morphological characterization and Ultra Violet-Visible (UV-Vis) Spectroscopy (Shimadzu, Model UV 1800) for optical analysis.

## RESULT AND DISCUSSIONS

### A. Cyclic voltammetry measurement

As previously mentioned, CV measurement was used to find the ideal region to deposit the n-type Cu<sub>2</sub>O thin film. It was done by applying sweeping potential from one potential value to a minimum potential then to a maximum potential and back to the first potential. For this measurement, the applied potential was from rest potential to -1.5 V and sweep to +1.0 V and back to rest potential vs Ag/AgCl. The rest potential (+0.1 V) was obtained from open circuit test which was applied before running the CV measurement.

Two main parameters were varied in this experiment which were the solution temperature and pH. For each temperature, two samples of different pH value were used. As shown in Table-1, the temperature values used were 50 °C and 60 °C while the pH values used were pH 5.5 and pH 6.5, respectively.

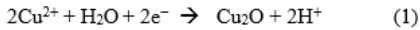
**Table-1.** Deposition parameters.

Sample	Solution temperature (°C)	Solution pH
1	50	5.5
2	50	6.5
3	60	5.5
4	60	6.5

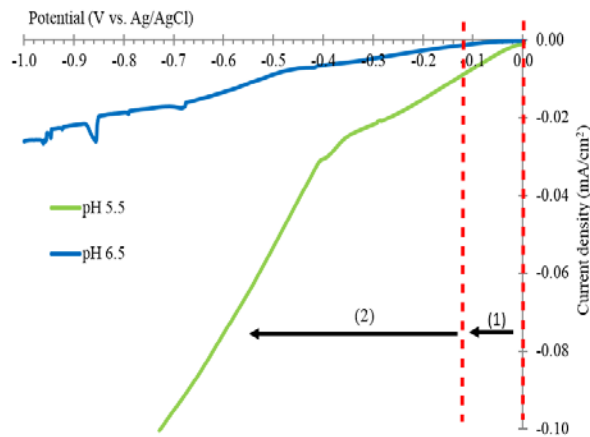
Figures 2 and 3 show the cyclic voltammetry plot for all samples. Different pH value of the Cu<sub>2</sub>O electrolyte with different temperature resulted in different range of oxidation and reduction process. By assuming the regions marked in Figure-2 and Figure-3 were the ideal range to



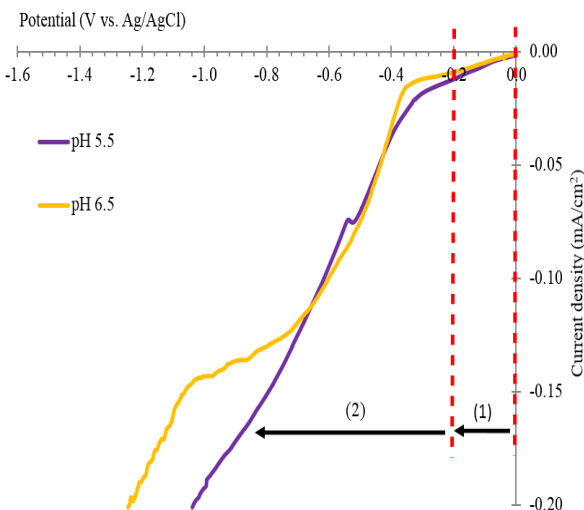
deposit n-type  $\text{Cu}_2\text{O}$  thin film, a potential value was selected for each sample. The main reduction process in this study is shown by:



From Figure-2 that shows deposition temperature of  $50^\circ\text{C}$ , the current densities drastically dropped indicating a quite narrow potential region for n- $\text{Cu}_2\text{O}$  deposition which was approximately between -0.1 V to -0.02 V vs Ag/AgCl. In Figure-3, the potential region for n- $\text{Cu}_2\text{O}$  deposition at  $60^\circ\text{C}$  was larger which was approximately between -0.2 V to 0 V vs Ag/AgCl. The selected potential for deposition of n- $\text{Cu}_2\text{O}$  was stated in Table-2.



**Figure-2.** Cyclic voltammetry plot for temperature  $50^\circ\text{C}$ .



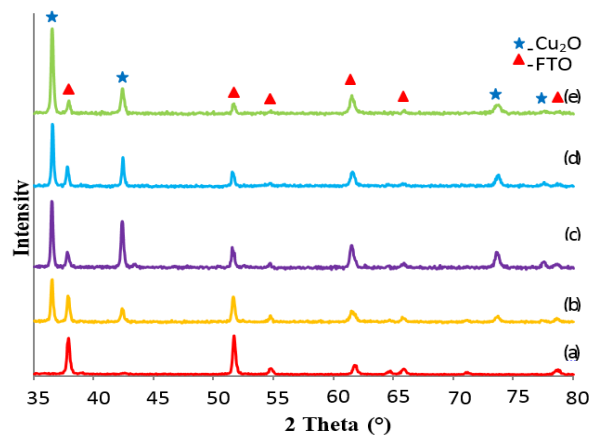
**Figure-3.** Cyclic voltammetry plot for temperature  $60^\circ\text{C}$ .

**Table-2.** Deposition parameter with selected potential.

Sample	Temperature ( $^\circ\text{C}$ )	pH	Potential applied (V vs. Ag/AgCl)
1	50	5.5	-0.05
2	50	6.5	-0.1
3	60	5.5	-0.05
4	60	6.5	-0.1

## B. Structural characterization

By using XRD, the structural state of  $\text{Cu}_2\text{O}$  electrodeposited on FTO substrate in different pH at different solution temperature were characterized. Figure 4 shows the stacked XRD pattern of all samples. In all samples, the XRD peaks were consistent with the standard peaks in JCPDS no. 050667 which determined the success formation of  $\text{Cu}_2\text{O}$  (Laidoudi et al, 2013). The peaks detected were at  $36.4^\circ$ ,  $42.3^\circ$ ,  $52.5^\circ$  and  $73.5^\circ$  corresponding to  $\text{Cu}_2\text{O}$  plane (111), (200), (211) and (311), respectively as shown in Table 3. The focused peak for fabrication of  $\text{Cu}_2\text{O}$  was the reflection at (111) formation which in this study, Sample 4 showed the highest peak. This indicates the structural improvement of  $\text{Cu}_2\text{O}$  crystallinity.



**Figure-4.** XRD spectrum for (a) FTO substrate, (b) Sample 1, (c) Sample 2, (d) Sample 3 and (e) Sample 4.

**Table-3.** Corresponding plane for  $\text{Cu}_2\text{O}$  reflection peaks.

2 Theta (Degree)	Planes [h k l]
36.4	[111]
42.3	[200]
52.5	[211]
73.5	[311]

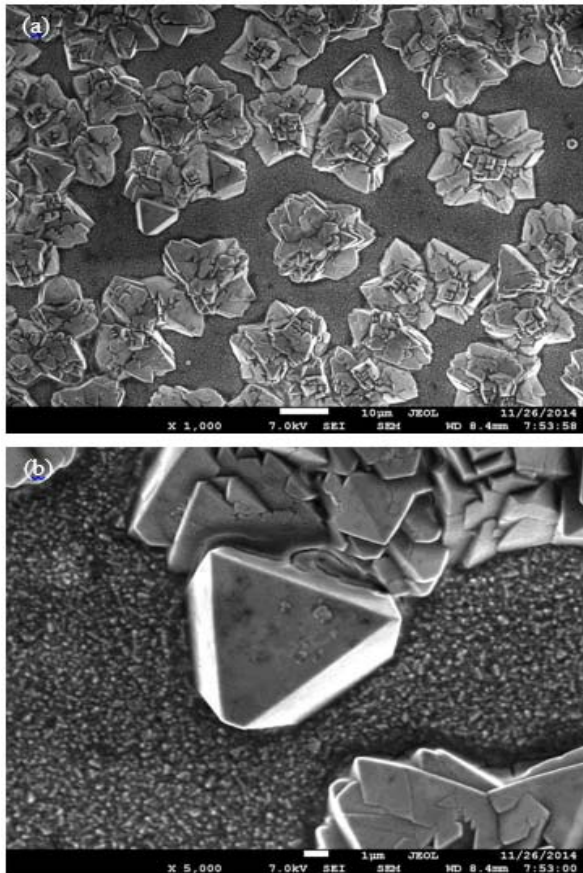


### C. Morphological characterization

Figures 5, 6, 7 and 8 shows the morphological evolution of  $\text{Cu}_2\text{O}$  thin films that were deposited under different solution pH at different solution temperature. FESEM images revealed the strong effect of deposition parameters towards composition and microstructure of  $\text{Cu}_2\text{O}$  thin films. Figure-5 shows the surface morphology for Sample 1 which was done using the parameters showed in Table-4. From figure, it can be seen that there were some triangular shapes which believed to represent  $\text{Cu}_2\text{O}$  shape (Papadimitropoulos *et al*, 2005). The 5K magnification image shows an individual triangular shape while the 1K magnification shows the thin films were forming several group of small islands with nanoflower shape.

**Table-4.** Deposition parameter for Sample 1.

pH	Potential (V vs. Ag/AgCl)	Temperature (°C)	Time (min)
5.5	-0.05	50	60

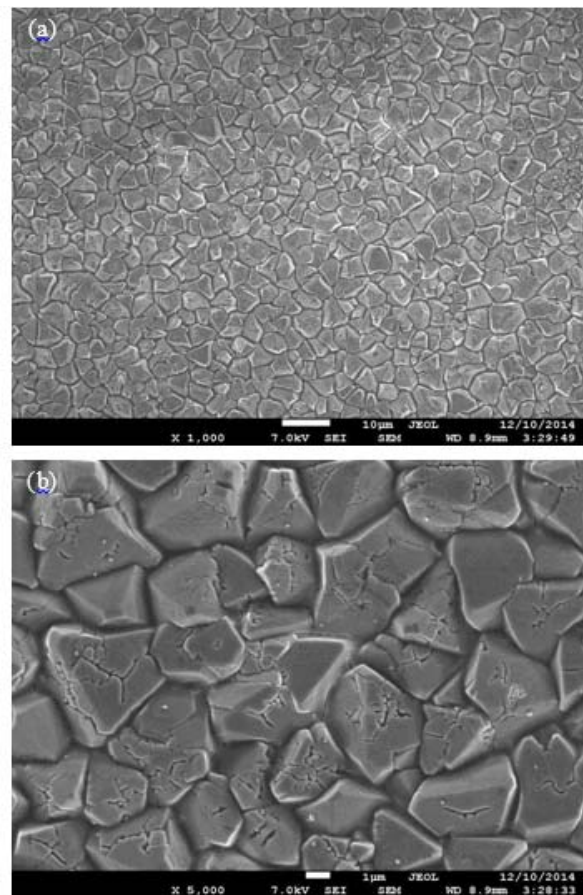


**Figure-5.** FESEM images of Sample 1 with (a) 1K and (b) 5K magnification.

Sample 2 was fabricated using parameter shown in Table-5. Figure-6 shows the FESEM image of Sample 2 which at 5K magnification, there were some triangular shapes that represent  $\text{Cu}_2\text{O}$ . The 1K magnification image shows evenly grown  $\text{Cu}_2\text{O}$  on the substrate. There were no spaces or gap between the grains. This indicated that at solution temperature 50 °C,  $\text{Cu}_2\text{O}$  solution with pH 6.5 was more homogenously deposited on FTO substrate compared to  $\text{Cu}_2\text{O}$  solution with pH 5.5.

**Table-5.** Deposition parameter for Sample 2.

pH	Potential (V vs. Ag/AgCl)	Temperature (°C)	Time (min)
6.5	-0.1	50	60



**Figure-6.** FESEM image of Sample 2 with (a) 1K and (b) 5K magnification.

Figure-7 shows Sample 3 fabricated using parameters shown in Table-6. As can be seen, there were also some triangular shape on the sample but with smaller grain compared to Sample 1 and 2. The structures were also not uniform on FTO substrate. While in Figure-8,



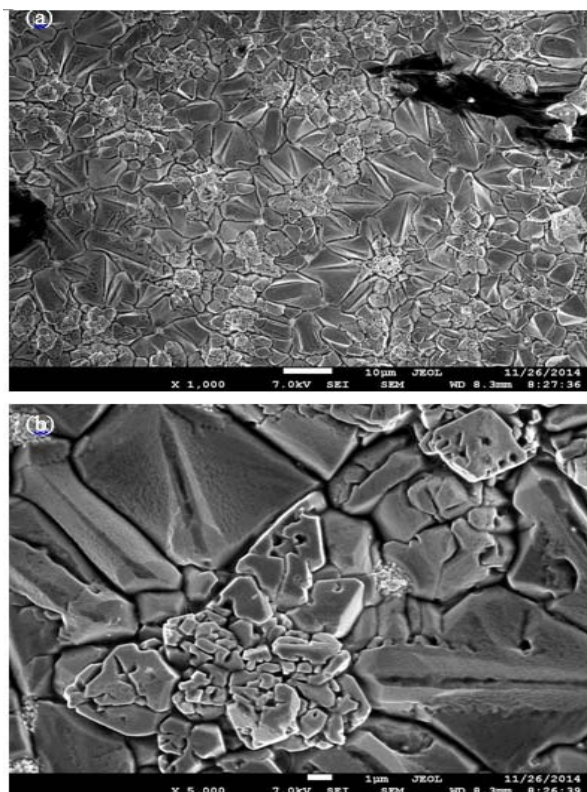


Sample 4 was fabricated using parameters as shown in Table-7. The grain sizes were significantly smaller but they were covering all the substrate with no gaps can be seen on the images. The small triangular shapes corresponding to  $\text{Cu}_2\text{O}$  were observed clearly on FTO substrate. The morphological characteristics of n- $\text{Cu}_2\text{O}$  thin film were consistent with the structural properties.

Some correlations can be concluded by doing morphological characterization. The temperature of  $\text{Cu}_2\text{O}$  solution affected the grain size of  $\text{Cu}_2\text{O}$  thin film. At one pH value, the sample with higher solution temperature exhibited smaller grain compared to lower temperature. The pH of  $\text{Cu}_2\text{O}$  solution affected the shape and distribution of  $\text{Cu}_2\text{O}$  on the FTO substrate. At pH 5.5 with different temperatures,  $\text{Cu}_2\text{O}$  deposited in groups that formed nanoflower-like shape. The grains were not homogeneously distributed. While at pH 6.5 with different temperature, the triangular shapes are more evenly distributed on FTO substrate.

**Table-6.** Deposition parameter for Sample 3.

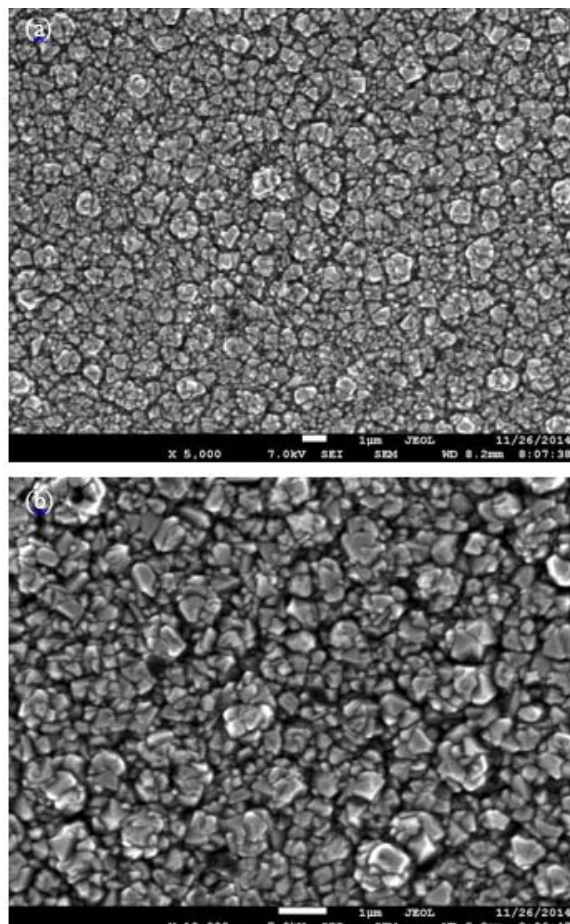
pH	Potential (V vs. Ag/AgCl)	Temperature (°C)	Time (min)
5.5	-0.05	60	60



**Figure-7.** FESEM images of Sample 3 with (a) 1K and (b) 5K magnification.

**Table-7.** Deposition parameter for Sample 4.

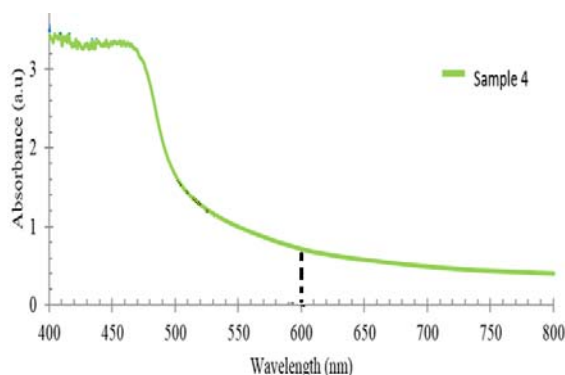
pH	Potential (V vs. Ag/AgCl)	Temperature (°C)	Time (min)
6.5	-0.1	60	60



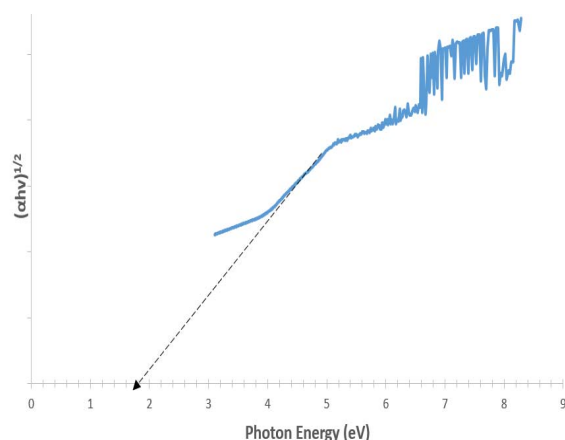
**Figure-8.** FESEM images of Sample 4 with (a) 1K and (b) 5K magnification.

#### D. Optical analysis

The absorbance of the samples was obtained from the result of UV-Vis analysis. The absorbance spectrums were used to calculate the band gap of the sample. The band gap was pointed out from the Tauc Plot which was the coefficient  $(\alpha h\nu)^{1/2}$  versus the photon energy (eV). Figure-9 shows the absorbance spectrum of the samples while Figure-10 shows the Tauc plot which was obtained from manipulating the data from the absorbance. The band gap for Sample 4 was 1.8 eV which is around the bandgap energy of  $\text{Cu}_2\text{O}$ .



**Figure-9.** Plot of absorbance versus wavelength for Sample 4.



**Figure-10.** Plot of  $(\alpha h\nu)^{1/2}$  versus the photon energy (eV) for Sample 4.

## CONCLUSIONS

N-type  $\text{Cu}_2\text{O}$  thin film were successfully fabricated onto FTO glass substrate by using electrodeposition method. Cyclic voltammetry measurements were used in order to understand the redox process and to obtain the ideal parameter range for deposition of  $\text{Cu}_2\text{O}$  thin film. From CV measurements, n- $\text{Cu}_2\text{O}$  with different temperature and pH were prepared. All samples were homogeneously grown on FTO glass substrate with typical triangular shape of  $\text{Cu}_2\text{O}$  except Sample 1 that exhibited nanoflower-shape of  $\text{Cu}_2\text{O}$ . The structural properties of  $\text{Cu}_2\text{O}$  were analysed and all samples possessed (111) preferred orientation. Among these samples, Sample 4 showed optimum structural properties.  $\text{Cu}_2\text{O}$  was homogeneously fabricated on the FTO substrate. This sample also absorbed light at wavelength 600 nm with the band gap energy of 1.8 eV. In conclusion, n- $\text{Cu}_2\text{O}$  thin film was successfully fabricated based on the deposition parameter obtained from CV measurement. Although some improvement is needed, the

results have opened a new door to fabricating homojunction thin film solar cell.

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